VEOLIA Value Proposition 1162

PRODUCT UPW systems

• INDUSTRY Semiconductor

 VALUE PROPOSITION Latest technologies used in UPW systems for chip producers

Veolia UPW System for ST Microelectronics

 To reach the TOC and Resistivity criteria, the raw water is treated in the Primary Make-Up system by combining the latest technologies: UV, Membrane Degasifier and Continuous De-ionization.

The Continuous De-ionization (CEDI) process produces a consistent water quality with a high percentage of feed water ion removal. CEDI systems operate without the use of chemicals, 24 hours a day and 7 days a week. There is regeneration requirement in CEDI and hence no downtime.

Ultrafiltration membranes are used in the Polishing loop to guarantee continuous high-quality water at the point of use. Intelligent engineering design allows us to incorporate the new systems into existing plant without any shutdown.